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PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Attn: OIPE

Masateru NAKAMURA

Group Art Unit: 1754

Application No.: 10/566,607

Docket No.: 126868

Filed: January 31, 2006

For: METHOD OF PRODUCTION OF SILICON CARBIDE SINGLE CRYSTAL

SECOND REQUEST FOR CORRECTION OF PALM RECORDS

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

A Request for Correction of PALM Records was filed on December 6, 2006. A copy of the Request, a marked-up copy of the Official Filing Receipt and a date stamped receipt is attached hereto.

It is respectfully requested that the Corrected Filing Receipt be immediately forwarded to the attorneys of record at the address set forth below.

Respectfully submitted,

James A. Oliff
Registration No. 27,075

Stephen P. Catlin
Registration No. 36,101

JAO:SPC/rdb

Date: June 6, 2007

OLIFF & BERRIDGE, PLC
P.O. Box 19928
Alexandria, Virginia 22320
Telephone: (703) 836-6400

<p>DEPOSIT ACCOUNT USE AUTHORIZATION Please grant any extension necessary for entry; Charge any fee due to our Deposit Account No. 15-0461</p>



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Alexandria, VA 22313-1450

Sir:

Attached is a corrected filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,

James A. Oliff
Registration No. 27,075

David R. Kemeny
Registration No. 57,241

JAO:DRK/msl

Date: December 6, 2006

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**PTO RECEIPT FOR FILING OF PAPERS**

Delivery ▶ Mail Room

The following papers have been filed:

Request for Correction of PALM Records; Marked-up Copy of Corrected Filing Receipt

Name of Applicant:	Masateru NAKAMURA
Serial No.:	10/566,607
Attorney File No.:	126868
Title:	Method of Production of Silicon Carbide Single Crystal
Sender's Initials:	JAO:DRK/msl
Assignee:	TOYOTA JIDOSHA KABUSHIKI KAISHA

PATENT OFFICE DATE STAMP

6

**COPY TO BE STAMPED BY PATENT OFFICE
AND RETURNED BY MESSENGER**

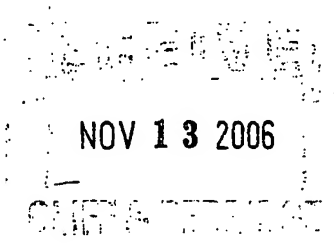


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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/566,607	07/24/2006 01/31/2006	1754	1030	126868	9	11	2

25944
OLIFF & BERRIDGE, PLC
P.O. BOX 19928
ALEXANDRIA, VA 22320



CONFIRMATION NO. 7140
CORRECTED FILING RECEIPT



OC000000021169333

Date Mailed: 11/09/2006

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 Alexandria Va 22313-1450. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

Masateru Nakamura, Toyota-shi, JAPAN;

Assignment For Published Patent Application

TOYOTA JIDOSHA KABUSHIKI KAISHA, Toyota-shi, JAPAN

Power of Attorney: The patent practitioners associated with Customer Number 25944.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP04/17652 11/19/2004

Foreign Applications

JAPAN 2003-394083 11/25/2003

If Required, Foreign Filing License Granted: 09/05/2006

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US10/566,607**

Projected Publication Date: 12/28/2006

Non-Publication Request: No

Early Publication Request: No

Title

Method of production of silicon carbide single crystal

Preliminary Class

423

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